

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|------|--|----------------------------------|------------------|---------|------------------|
| L1 | 27 | ((polishing and etching) and trench adj insulation).clm. | US-PGPU B; USPAT; EPO; JPO | OR | ON | 2005/11/20 09:42 |
| L2 | 0 | ((polishing and etching) and trench adj insulation and overfill).clm. | US-PGPU B; USPAT; EPO; JPO | OR | ON | 2005/11/20 09:43 |
| L3 | 0 | ((polishing and etching) and trench adj insulation and outermost).clm. | US-PGPU B; USPAT; EPO; JPO | OR | ON | 2005/11/20 09:43 |
| L4 | 22 | ((polishing and etching) and trench adj insulation and substrate).clm. | US-PGPU B; USPAT; EPO; JPO | OR | ON | 2005/11/20 09:43 |